

FORM PTO-1449/A and B (Modified) INFORMATION DISCLOSURE STATEMENT BY APPLICANT				APPLICATION NO.: Not yet assigned		ATTY. DOCKET NO.: S1459.70074US00	
				FILING DATE: Herewith		CONFIRMATION NO.: Not yet assigned	
				APPLICANT: Koji Kadono et al.			
				GROUP ART UNIT: Not yet assigned		EXAMINER: Not yet assigned	
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U.S. PATENT DOCUMENTS

Examiner's Initials	Cite No.	U.S. Patent Document		Name of Patentee or Applicant of Cited Document	Date of Publication or of issue of Cited Document MM-DD-YYYY
		Number	Kind Code		

FOREIGN PATENT DOCUMENTS

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Examiner's Initials	Cite No.	Foreign Patent Document			Name of Patentee or Applicant of Cited Document (not necessary)	Date of Publication of Cited Document MM-DD-YYYY	Translation (Y/N)
		Office/ Country	Number	Kind Code			
/MW/	1	PCT	WO00/19494	A1	Xidex Corporation 412000	04-06-2004	Y
/MW/	2	Japan	JP05-205615	A		08-13-1993	N
/MW/	3	Japan	JP2003-146632	A		05-21-2003	N

OTHER ART — NON PATENT LITERATURE DOCUMENTS

Examiner's Initials	Cite No	Include name of the author (in CAPITAL LETTERS) title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, relevant page(s), volume-issue number(s), publisher, city and/or country where published.	Translation (Y/N)	
/MW/	4	MATSUI, S. et al., "Three-dimensional nanostructure fabrication by focused-ion-beam chemical vapor deposition," J. Vac. Sci. Technol. B, Vol. 18, No. 6, 2000, pp. 3181-3184		

EXAMINER: /Mary Wilczewski/	DATE CONSIDERED: 09/14/2008
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